Ami	perometry	re	port
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## Experiment parameters

Method					
Potential steps/V		Potential duration	/s	Interval time/s	Current range
High sensitivity	Stability / speed	Integrator	Conditioning/V	Conditioning/s	Equilibration/s
Cell off after measur	rement	Standby pot./V	Define potential w	.r.t. OCP	Wait for OCP/s
Instrument			Computer		

## Electrodes

Sampleid	Cleaned	Substrate mass/g		
RE	CE	Sample substrate		
Remarks during experiment				
Deposit area (projected)/cm <sup>2</sup>	Deposit appearance		Deposit mass/mg	

## Electrolyte

Electrolyte id			Precursors		
Volume/ml	Temp/°C	Stirring	Gas	Temperature control method	
Remarks after experiment					

## Electrode configuration and other inlets/outlets

